

Title (en)
ELECTROCHEMICAL PROCESSING CELL

Title (de)
ELEKTROCHEMISCHE VERARBEITUNGSZELLE

Title (fr)
CELLULE DE TRAITEMENT ELECTROCHIMIQUE

Publication
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Application
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Abstract (en)
[origin: WO2005007933A1] Embodiments of the invention provide an electrochemical plating cell (100). The plating cell includes a fluid basin (101), (102) having an anolyte solution compartment and a catholyte solution compartment, an ionic membrane (112) positioned between the anolyte solution compartment and the catholyte solution compartment, and an anode positioned in the anolyte solution compartment, wherein the ionic membrane comprises a poly tetrafluoroethylene based ionomer.

IPC 8 full level
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CPC (source: EP)
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